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Information Disclosure Citation in an Application			Application No.	Applicant(s)		#7	
			09/862,814	John C. Sei	John C. Seibel et al.		
			Docket Number	Group Art		Filing Date 01-06-	
			067082.0114	2177	5/21/01		
JEC 197	oog 🛜	-	U.S. PATENT DOCUMENTS	6	*		
	CUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
TRADE	4914586	4/3/90	Swinehart et al.	364	200	11/6/87	
В	6034970	3/7/00	Levac et al.	370	466	7/2/97	
С	6199081	3/6/01	Meyerzon et al.	707	513	6/30/98	
_ D	6493703	12/10/02	Knight et al.	707	3	5/11/99	
E	6609124	8/19/03	Chow et al.	707	5	8/13/01	
F	6611839	8/26/03	Nwabueze	707	101	3/15/01	
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			FOREIGN PATENT DOCUMEN	NTS	\wedge		
	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATIO YES NO	
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			NON-PATENT DOCUMENTS	S	100 3	2 (1)	
		DOCUMENT (Incl	uding Author Title Source and			DATE	
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